## **SEMICONDUCTOR DEVICES**

## **Test Paper-I**

MAX MARKS: 30 TIME: 90Mts

SI. No.	QUESTION	ANSWER PAGE	MARKS
1	Briefly explain how a vacuum tube works does and what the other		2
_		Page:467	
2	What are the limitations of vacuum tubes?	Page:467	2
3	Give any two differences between a vacuum tube and a semiconductor device.		2
		Page:468	_
4	What are energy bands?	Page:469	2
5	What is a valence band, a conduction band?	Page:469	
6	Differentiate between a metallic conductor, semiconductor, and an insulator basing		
	on the energy band theory of solids.	Page:471	3
7	What is an intrinsic semiconductor? Discuss its behaviour as the temperature		2
	increases.	Page:474	
8	C, Si and Ge have same lattice structure. Why is C insulator while Si, and Ge intrinsic		2
	semiconductors?	Page:474	
9	What is an extrinsic semiconductor? How is it different from an int	rinsic	1
	semiconductor	Page:474	
10	Name the different types of extrinsic semiconductors. Briefly explain how an n-type		
	semiconductor is formed?	Page:475	3
11	Briefly explain how a p-type semiconductor is formed? Give any two differences		
	betweenap-typesemiconductorandan-typesemiconductor.	Page:476 & 477	3
12	Give the relation between electron and hole concentration in a semiconductor in		
	thermal equilibrium.	Page:477	1
13	Suppose a pure Si crystal has 5 X 10 <sup>28</sup> atoms m <sup>-3</sup> . It is doped by 1 pp	m concentration	2
	of pentavalent As. Calculate the number of electrons and holes.		
	Given that $n_i$ =1.5 X $10^{16}$ m <sup>-3</sup> .	Page:477	
14	Explain how p-n junction diode is formed. What are the process inv	olved in it?	3
		Page:478	
15	Can we take one slab of p-type semiconductor and physically join to another n-type		2
	semiconductor to get p-n junction?	Page:479	